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## Amendments to the Claims:

This listing of claims replaces all prior versions and listings of claims:

 (Currently Amended) A data recording element for a memory cell of a writable and erasable memory medium comprising:

a laminated structure of at least two multiple-layer structures, each said multiplelayer structure comprising a plurality of individual layers, at least one of the plurality of individual layers in each multiple-layer structure being made of a material capable of changing phase between a crystalline state and an amorphous state in response to an electrical pulse, <u>and</u> one of the plurality of individual layers <u>of one of said at least two</u> <u>multiple-layer structures</u> having at least one atomic element which is absent from a <u>second</u> <u>other</u> on of <u>the said</u> plurality of individual layers, <u>and</u>

a final individual layer disposed upon at least two multiple-layer structures, said final individual layer being formed of the same material as a first of said plurality of individual layers in a first of said at least two multiple-layer structures of said laminated structure wherein a crystallization speed of said first of said plurality of individual layers of said first of said at least two multiple-layer structures and said final individual layer is higher than that of other ones of said plurality of individual layers of said first multiple layer structure and a crystallization temperature of said first of said plurality of individual layers of said first of said at least two multiple-layer structures and said final individual layer is lower that other ones of said plurality of individual layers of said first of said at least two multiple-layer structures of said first of said at least two multiple-layer structures.

- (Currently amended) The data recording element as recited in claim 1, wherein the
  plurality of sequentially-disposed individual layers in a first one and a second one of said
  at least two multiple-layer structures are disposed in a same sequence in at least two said
  multiple-layer structures.
- (Currently amended) The data recording element as recited in claim 1, wherein the
  plurality of sequentially disposed individual layers in a first one and a second one of said
  at least two multiple-layer structures are disposed in a different sequence in at least two
  said multiple-layer structures.

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 (Currently amended) The data recording element as recited in claim 1, wherein each of said plurality of layers in each of said at least two multiple-layer structures individual layer has a thickness in a range of about 0.1 nm to about 10 nm.

- (Currently amended) The data recording element as recited in claim 1, wherein all each
  of the individual layers in each of said at least two multiple-layer structures
  have the same thickness.
- (Currently amended) The data recording element as recited in claim 1, wherein any two
  neighboring adjacent ones of the plurality of individual layers in one of said at least two
  multiple-layers structures have a ratio of thickness of about 0.1 to about 10.
- (Original) The data recording element as recited in claim 1, wherein the total thickness of the data recording element is in a range of about 5 nm to about 500 nm.
- (Currently amended) The data recording element as recited in claim 71, wherein the total
  thickness of the data recording element individual layers is in a range of about 5 nm to
  about 100 nm.
- (Currently amended) The data recording element as recited in claim 1, wherein at least
  one of the plurality of individual layers is formed of a material selected from a group
  consisting of Ge, Te, Sb, Ag, GeTe, SbTe, AgIn, GeSbTe, AgInSbTe, TeAsGe, TeSeS,
  TeSeSb, InSbTe, TeGeSn, In, Cr, N, Se, Sn, Si, Bi, and Ag.
- (Original) The data recording element as recited in claim 1, wherein said at least one of the plurality of individual layers is deposited in a crystalline state.
- (Currently amended) The data recording element as recited in claim 1, wherein a
  resistance of said at least one of said plurality of individual layer layers is lower in [[an]]
  a crystalline state than that in an amorphous state.
- 12. (Canceled)
- 13. (Canceled)

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14. (Currently amended) The data recording element as recited in claim 13 1, wherein the crystallization temperature of said first individual layer and final individual layer of first of said plurality of individual layers in said first of said at least two multiple-layer structures of said laminated structure is in a range of about 90°C to 120°C.

- 15. (Currently amended) The data recording element as recited in claim +2 1, further comprising an electrode formed adjacent to the data recording element, an edge of the electrode contacting the data recording element for transferring electrical signals between the electrode and the data recording element.
- (Original) The data recording element as recited in claim 1, wherein said laminated structure forms a superlattice-like structure.
- 17. (Currently amended) A data recording element for a memory cell of a writable and erasable memory medium comprising:
  - a laminated structure having a first external layer, a second external layer and a plurality of internal layers formed between the first and second external layers, at least one layer of the laminated structure being made of a material capable of changing phase between a crystalline state and an amorphous state in response to an electrical pulse.
  - wherein said first and second external layers have a relatively higher crystallization speed and lower crystallization temperature than the plurality of internal layers.
- 18. (Canceled)
- (Currently amended) The data recording element as recited in claim 18 17, wherein the
  crystallization temperature of said first and second external layers is in a range of about
  90°C to 120°C.
- 20. (Currently amended) A memory cell for a writable and erasable memory medium comprising:

a substrate:

first and second contacts formed on said substrate;

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> a data recording element formed between said first and second contacts, said data recording element comprising a laminated structure of two or more multiplelayer structures and a final individual layer disposed upon said at least two multiple-layer structures;[,] each of said at least two multiple-layer structure structures comprising a plurality of sequentially disposed individual layers, at least one of said plurality of sequentially disposed individual layer layers in each of said at least two multiple-layer structure-structures being a material capable of changing phase between a crystalline state and an amorphous state in response to an electrical pulse, one of the plurality of sequentially disposed individual layers having at least one atomic element which is absent from other a second one of the plurality of sequentially disposed individual layers; said final individual layer being formed of the same material as a first of said plurality of sequentially disposed individual layers in a first of said at least two multiple-layer structures of said laminated structure wherein a crystallization speed of said first of said plurality of sequentially disposed individual layers of said first of said at least two multiple-layer structures and said final individual layer is higher than that of other ones of said plurality of sequentially disposed individual layers of said first of said at least two multiple-layer structures and a crystallization temperature of said first of said plurality of sequentially disposed individual layers of said first of said at least two multiple-layer structures and said final individual layer is lower that other ones of said plurality of sequentially disposed individual layers of said first of said at least two multiple-layer structures:

- a high temperature electrode formed adjacent the data recording element; and an insulating material isolating said memory cell from adjacent memory cells.
- (Currently amended) An electrically writable and erasable memory medium comprising a
  plurality of memory cells and an arrangement of conductors such that each of said plurality of
  memory eell cells is electrically addressable, each said memory cell comprising;
  - a substrate:

first and second contacts formed on said substrate;

a data recording element formed between said first and second contacts, said data recording element comprising a laminated structure of two or more multiple-layer structures and a final individual layer disposed upon said at least two multiple-layer structures;[,] each of said at least two multiple-layer structures.

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> structures comprising a plurality of sequentially disposed individual layers, at least one of said plurality of sequentially disposed individual laver layers in each of said at least two multiple-layer structure-structures being a material capable of changing phase between a crystalline state and an amorphous state in response to an electrical pulse; one of the plurality of sequentially disposed individual layers having at least one atomic element which is absent from other a second one of the plurality of sequentially disposed individual layers; said final individual layer being formed of the same material as a first of said plurality of sequentially disposed individual layers in a first of said at least two multiple-layer structures of said laminated structure wherein a crystallization speed of said first of said plurality of sequentially disposed individual layers of said first of said at least two multiple-layer structures and said final individual layer is higher than that of other ones of said plurality of sequentially disposed individual layers of said first of said at least two multiple-layer structures and a crystallization temperature of said first of said plurality of sequentially disposed individual layers of said first of said at least two multiple-layer structures and said final individual layer is lower that other ones of said plurality of sequentially disposed individual layers of said first of said at least two multiple-layer structures;

a high temperature electrode formed adjacent the data recording element; and an insulating material isolating said memory cell from adjacent memory cells.

22. (Withdrawn) A method of producing a data recording element for a memory cell of electrically writeable and erasable memory medium, the method comprising:

depositing a first multiple-layer structure on a substrate; said multiple-layer structure consisting of at least two individual layers, at least one of said individual layers being a material capable of changing phase between a crystalline state and an amorphous state in response to an electrical pulse; depositing one or more further multiple-layer structures on said first multiple-layer structures comprising at least two individual layers, at least one of said individual layers being a material capable of changing phase between a crystalline state and an amorphous state in response to an electrical pulse, wherein one individual layer of said first and further multiple layer structures

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having at least one atomic element which is absent from another individual layer.

- 23. (Withdrawn) The method as recited in claim 22, further comprising depositing a final individual layer formed of a same material as a first individual layer of said first multiple-layer structure.
- 24. (Withdrawn) The method as recited in claim 23, wherein said first and final individual layers having a relatively high crystallization speed and low crystallization temperature than other layers of the first and further multiple-layer structure.
- 25. (Withdrawn) The data recording element as recited in claim 24, wherein the crystallization temperature of said first and final individual layers is in a range of about 90°C to 120°C.
- 26. (Withdrawn) A method of producing a memory cell for a writeable and erasable memory medium, comprising:

depositing an insulating material on a substrate;

depositing a first contact on said insulating material;

depositing a high temperature electrode adjacent said first contact;

sequentially depositing two or more multiple-layer structures to form a data recording element, each said multiple-layer structure comprising two or more individual layers, at least one said individual layer in each said multiple-layer structure being formed from a material capable of changing phase between a crystalline state and an amorphous state in response to an electrical pulse; one of the plurality of individual layers having at least one atomic element which is absent from other one of the plurality of individual layers:

depositing a second contact on said data recording element; and depositing further insulating material to isolate said memory cell from adjacent memory cells.

27. (Withdrawn) The method as recited in claim 26, further comprising depositing a final individual layer formed of a same material as a first individual layer of said first multiple-layer structure.

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28. (Withdrawn) A method of writing and erasing information to an electrically writeable and erasable memory medium having a plurality of memory cells and an arrangement of conductors such that each memory cell is electrically addressable, each memory cell comprising:

a substrate:

first and second contacts formed on said substrate;

- a data recording element formed between said first and second contacts, said data recording element having a laminated structure of two or more multiple-layer structures, each said multiple-layer structure having a plurality of sequentially disposed individual layers, at least one of said individual layers in each multiple-layer structure being a phase-change material capable of changing phase between a crystalline state and an amorphous state in response to an electrical pulse, one of the plurality of individual layers having at least one atomic element which is absent from other one of the plurality of individual layers; and
- a high temperature electrode formed adjacent the data recording element; the method including:
  - applying an energy pulse to said data recording element via said high temperature electrode, said energy pulse supplying sufficient energy to change said phase-change material between a crystalline phase and an amorphous phase.
- 29. (Withdrawn) The method as recited in claim 28, wherein said energy pulse is a single pulse.
- (Withdrawn) The method as recited in claim 28, wherein said energy pulse is a chain of multi-pulses.
- 31. (Withdrawn) The method as recited in claim 28, wherein said energy pulse has a duration of less than about 50 ns for data writing.
- 32. (Withdrawn) The method as recited in claim 30, wherein said energy pulse has a duration of not more than 7 ns for data writing.
- 33. (Withdrawn) The method as recited in claim 28, wherein said energy pulse has a duration of less than about 50 ns for data erasing.

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34. (Withdrawn) The method as recited in claim 32, wherein said energy pulse has a duration of not more than about 10 ns for data erasing.